

# CITATION REPORT

List of articles citing

Effect of substrate-induced lattice strain on the electrochemical properties of pulsed laser deposited nickel oxide thin film

DOI: 10.1016/j.mseb.2022.115711

Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 2022, 280, 115711.

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#	Paper	IF	Citations
2	Modulation of the conductive behavior of NiO thin film deposited by HiPIMS through varying the O2 flow ratio. <b>2022</b> ,		
1	Modulation of Structural, Electronic, and Optical Properties of Titanium Nitride Thin Films by Regulated In Situ Oxidation.		0